Dynamics of thin-lm spin-ip transistors with perpendicular source-drain magnetizations

X uhui W ang and G errit E.W. Bauer K avli Institute of NanoScience, Delft University of Technology, 2628 CJ Delft, The Netherlands

Axel Homann

M aterials Science Division and Center for Nanoscale Materials, Argonne National Laboratory, Argonne, Illinois 60439, USA (Dated: February 8, 2022)

A \spin- ip transistor" is a lateral spin valve consisting of ferrom agnetic source drain contacts to a thin- lm norm al-m etal island with an electrically oating ferrom agnetic base contact on top. We analyze the dc-current-driven magnetization dynamics of spin- ip transistors in which the source-drain contacts are magnetized perpendicularly to the device plane by magnetoelectronic circuit theory and the macrospin Landau-Lifshitz-Gilbert equation. Spin ip scattering and spin pumping elects are taken into account. We note a steady-state rotation of the base magnetization at GHz frequencies that is tuneable by the source-drain bias. We discuss the advantages of the lateral structure for high-frequency generation and actuation of nanom echanical systems over recently proposed nanopillar structures.

I. INTRODUCTION

Current induced magnetization excitation by spin-transfer torque^{1,2} attracts considerable attention because of potential applications for magnetoelectronic devices. The prediction of current-induced magnetization reversal has been con med experimentally in multilayers structured into pillars of nanometer dimensions.^{3,4,5,6} The devices typically consist of two ferromagnetic layers with a high (xed layer) and a low coercivity (free layer), separated by a normal metal spacer. The applied current ows perpendicular to the interfaces. Of the magnetic anisotropies force the magnetizations into the plane of the magnetic layers. Recently a number of theoretical proposals pointed out interesting dynamics when the magnetization of one of the layers is oriented perpendicular to the interface planes.^{7,8,9}

Fundam ental studies of charge and spin transport have also been carried out in thin-lm metallic conductors structured on top of a planar substrate. 10,11,12,13,14,15 The advantages compared to pillar structures are the exible design and the relative ease to fabricate multi-term in al structures with additional functionalities such as the spintorque transistor. The easy accessibility to microscopic imaging of the structure and magnetization distribution should make the lateral structure especially suitable to study current-induced magnetization dynamics. Previous studies focused on the static (dc) charge transport properties, but investigations of the dynamics of laterally structured devices are underway. 17,18 Recently, non-local magnetization switching in a lateral spin valve structure has been dem onstrated. 19 In the present paper we investigate theoretically the dynamics of a lateral spin valve consisting of a normal metal lm that is contacted by two magnetically hard ferromagnets. As sketched in Fig. 1, a (nearly) circular and magnetically soft ferromagnetic Im is assumed deposited on top of the normal metal to form a spin-ip transistor. We concentrate on a con quration in which the magnetization direction of the source-drain contacts lies perpendicular to the plane of the magnetization of the third (free) layer. This can be realized either by making the contacts from a m aterial that has a strong crystalline m agnetic anisotropy forcing the m agnetization out of the plane, such as Co/Ptmultilayers, 21 or by growing the source/drain ferrom agnetic contacts into deeply etched groves to realize a suitable aspect ratio. In such a geometry, the magnetization of the free layer precesses around the demagnetizing eld that arises when the magnetization is forced out of the plane by the spin-transfer torque, as has been discussed in Refs. 7,8,9. Therefore, as long as the out-of-plane magnetization of the free layer remains small, the free layer m agnetization will always stay almost perpendicular to the source and drain magnetizations. In the present article we analyze in depth the coupled charge-spin-magnetization dynamics in such current-biased thin-lim \magnetic fans" and point out the di erences and advantages compared to the perpendicular pillar structures. A convenient and accurate tool to compute the dynamic properties of our device is the magnetoelectronic circuit theory for charge and spin transport²⁰ coupled to the Landau-Lifshitz-Gilbert equation in the macrospin model. We include spin ip scattering in normal and ferrom agnetic metals and the spin-pumping eect. 22,23

The article is organized as follows: In Section II, we brie y review the Landau-Lifshitz-Gilbert equation including the current driven and spin-pumping torques that can be derived by circuit theory. In Section III, the speci c results for our \mbox{m} agnetic fan" are presented. The potential applications will be discussed in Section IV. Section V is devoted to the conclusion.

II. FORM ALISM

We are interested in the magnetization dynamics of the soft ferrom agnetic island (i.e., composed of permalloy) on top of the normal in as sketched in the Fig. 1. The Landau-Lifshitz-Gilbert (LLG) equation in the macrospin model, in which the ferrom agnetic order parameter is described by a single vector M with constant modulus M_s , appears to describe experiments of current-driven magnetization dynamics well, although some open questions remain. In crommagnetic calculations of the perpendicular magnetization conguration in the pillar structure suggest a steady precession of the magnetization. The LLG equation for isolated ferrom agnets has to be augmented by the magnetization torque L that is induced by the spin accumulation in proximity of the interface as well as the spin pumping:

$$\frac{1}{dt} \frac{dm}{dt} = m H_{eff} + \frac{0}{m} \frac{dm}{dt} + \frac{1}{VM_s} L$$
 (1)

where is the gyrom agnetic constant, $m = M = M_s$ and H_{eff} is the magnetic eld including demagnetizing, an isotropy or other external elds. 0 is the G ilbert damping constant and V is the volume of the isolated bulk magnet.

$$L = m I_s^{(p)} + I_s^{(b)} m;$$

where $I_s^{(p)}$ and $I_s^{(b)}$ denote the pum ped^{22} and bias-driven^{1,2} spin currents leaving the ferrom agnet, respectively, and the vector products project out the components of the spin current normal to the magnetization direction.

In magnetoelectronic circuit theory a given device or circuit is split into nodes and resistors. In each node a charge potential and spin accumulation is excited by a voltage or current bias over the entire device that is connected to reservoirs at them all equilibrium or by spin pumping. The currents are proportional to the chemical potential and spin accumulation differences over the resistors that connect the island to the nodes. The Kirchho nules representing spin and charge conservation close the system of equations that govern the transport. In the following we assume that the ferrom agnetic layer thickness is larger than the magnetic coherence length $_{\rm C} = = k_{\rm F}^{\rm m} - k_{\rm F}^{\rm m}$ in terms of the

m a jority and m inority Ferm i wave numbers that in transition metal ferrom agnets is of the order of Angstroms.

Let us consider a ferrom agnet-norm alm etal (F N) interface in which the ferrom agnet is at a chem ical potential $_0^F$ and spin accumulation $_s^F$ m (with magnetization direction m), whereas the normal metal is at $_0^N$ and spin accumulation s. The charge current (in units of Ampere) and spin currents (in units of Joule), into the normal metal are $_0^{26}$

$$I_{c} = \frac{e}{2h} \left[2g \left(\begin{smallmatrix} F \\ 0 \end{smallmatrix} \right)^{N} \right) + pg \begin{smallmatrix} F \\ s \end{smallmatrix} pgm \quad s \right]$$

$$I_{s}^{(b)} = \frac{g}{8} \left[2p \left(\begin{smallmatrix} F \\ 0 \end{smallmatrix} \right)^{N} \right) + \begin{smallmatrix} F \\ s \end{smallmatrix} \right] (1 \quad _{r})m \quad s m$$

$$\frac{g}{8} \quad _{r}s \quad \frac{g}{8} \quad _{i}(s \quad m)$$

$$(3)$$

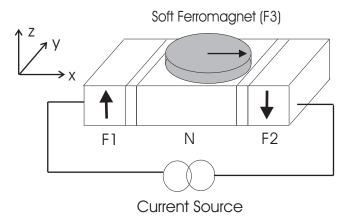


FIG. 1: The model system consists of hard-magnetic source and drain contacts (F1 and F2) with antiparallel magnetizations perpendicular to the plane. On the top of the normal metal N, a soft ferromagnetic lm (F3) is deposited with a slightly elliptical shape. The quantization direction, i.e., z-axis, is chosen parallel to the magnetization of the source and the drain.

where $_{0}^{F}$ and $_{0}^{N}$ are the chemical potentials in the ferrom agnets and normal metal, respectively. g''; $g^{\#}$ are the dim ensionless spin dependent conductances with polarization $p = (g'' g'') = (g'' + g^{\#})$ and total contact conductance $g = g'' + g^{\sharp}$. In the Landauer-Buttiker form alism

$$g^{"(\#)} = M \qquad jr_{"(\#)}^{nm} j^{2} \qquad (4)$$

where M is the total number of channels and $r_{\pi(\#)}^{nm}$ is the rejection coefcient from mode m to mode n for spin up (down) electrons. The spin transfer torque is governed by the complex spin-mixing conductance $g^{"\dagger}$, given by 26

$$g^{"\#} = M$$
 $r_{"}^{nm} (r_{\#}^{nm}) ;$ (5)

introduced in Eq. (3) in terms of its real and imaginary part as $_{\rm r} = 2 {\rm Reg}^{"\#} = {\rm g}$ and $_{\rm i} = 2 {\rm Im} \, {\rm g}^{"\#} = {\rm g}$. All conductance param eters can be computed from st principles as well as tted to experiments.

Slonczew ski's spin transfer torque can then be written as

m
$$\frac{4}{5}$$
 m = $\frac{g}{8}$ r[s (s m)m] $\frac{g}{8}$ i(s m): (6)

The spin-pum ping current is given by 22

$$I_s^{(p)} = \frac{h}{8}g \quad _r m \quad \frac{dm}{dt} + i \frac{dm}{dt} \quad ; \tag{7}$$

We consider for sim plicity the regime in which the spin-ip divusion length l_{sf}^N in the normal metal node is larger than the size of the norm alm etal region. 12 Charge and spin currents into the norm alm etal node are then conserved such that²⁰

$$X I_{c;i} = 0 (8)$$

$$X I_{c;i} = 0$$

$$X I_{s;i}^{(p)} + I_{s;i}^{(b)} = I_{s}^{sf};$$
(8)

where we introduce a leakage current due to the spin- ip scattering $I_s^{sf} = g_{sf} s=4$ and $g_{sf} = h_{DOS} V_N = \frac{N}{sf}$ is the conductance due to spin ip scattering, where DOS is the (on-spin) density of state of the electrons in the normal m etal, $\frac{N}{sf}$ is the spin ip relaxation time and V_N the volume of the normal metal node.

The polarization of the source-drain contacts is supposed to be an elective one including the magnetically active region of the bulk ferrom agnet with thickness governed by the spin-ip di usion length in the ferrom agnet. For the free magnetic layer F 3, the perpendicular component of the spin current is absorbed to generate the spin transfer torque. The collinear current has to ful 11 the boundary conditions in terms of the chemical potential $\frac{F}{S} = \frac{1}{N}$ governed by the di usion equation

$$\frac{{{\binom{g^2}}_{s}}^{F}(z)}{{{\binom{g}}_{z^2}}} = \frac{{\binom{F}}_{s}}{{\binom{F}}_{sd}}^{2} :$$
 (10)

where I_{sd}^F is the spin ip di usion length in the ferrom agnet.

III. SPIN TRANSFER TORQUE AND MAGNETIC FAN EFFECT

In this Section, we solve the Landau-Lifshitz-Gilbert equation including expressions for the spin-transfer torque on the free layer according to the circuit theory sketched above.

A. Currents and spin torque

In m etallic structures the imaginary part of the mixing conductance is usually very small and may be disregarded, i.e., i '0. The source and drain contacts F1N and F2N are taken to be identical: $g_1 = g_2 = g$, $p_1 = p_2 = p$ and $_{\rm r1}$ = $_{\rm r2}$ $_{\rm r}$. For F 3 N we take $_{\rm r3}$ $_{\rm 3}$. In our device, the directions of the m agnetization of the xed m agnetic leads are m $_{\rm 1}$ = (0;0;1) and m $_{\rm 2}$ = (0;0;1). For the free layer we allow the m agnetization m $_{\rm 3}$ = $(m_{\rm x};m_{\rm y};m_{\rm z})$ to be arbitrary. We assume that F 3 is a oating contact in which the the chemical potential $_{\rm 0}^{\rm F3}$ adjusts itself such that the net charge current through the interface F 3 N vanishes:

$$I_{c}^{(3)} = \frac{eg_{3}}{2h} \left[2 \left(\begin{smallmatrix} F & 3 \\ 0 \end{smallmatrix} \right) + p_{3} \begin{smallmatrix} F & 3 \\ s \end{smallmatrix} \right) p_{3} s \quad p_{3} s \quad p_{3} s \quad p_{3} s$$
 (11)

Applying a bias current I_0 on the two ferrom agnetic leads, F1 and F2, the conservation of charge current in the normal metal then gives $I_c^{(1)} = I_0^{(2)} = I_0$. At the F3N interface, the continuity of the longitudinal spin current dictates

"
$$\frac{\theta}{\theta z}$$
" $= \frac{\theta}{\theta z}$ $= \frac{2e^2}{hA} I_{s;3}$ rg (12)

where $_{"}(_{\#})$ is the bulk conductivities of spin up (down) electrons in the ferrom agnet and A the area of the interface. Choosing the origin of the z axis is at the F 3 N interface and assuming F 3 to be of thickness d,

"
$$\frac{\theta}{\theta z}$$
 $z = d$ # $\frac{\theta}{\theta z}$ $z = d$ = 0: (13)

With both boundary conditions, the di usion equation can be solved for the spin accumulation in F3

$$\frac{F}{S}(z) = \frac{3 \cosh(\frac{z d}{l_{Sd}^{F}}) s m_{Sd}}{3 + \sim \tanh(\frac{d}{l_{Sd}^{F}}) \cosh(\frac{d}{l_{Sd}^{F}})}$$
(14)

where $_3=g_3$ (1 $_3^2$)=4 characterizes the contact F 3 N and $_{}^{\sim}=hA$, $_{\#}=(e^2\,l_{\rm sd}^F\,($, $_{\#}+$ $_{\#}))$ describes the bulk conduction properties of the free layer with arbitrary m $_3$. The lim it d $_{\rm sd}^F$ corresponds to negligibly small spin- ip, which implies tanh (d= $l_{\rm sd}^F$) ' 0. Near the interface, the spin accumulation in F 3 then reduces to

$$s^{F3} = s mg (15)$$

In this $\lim_{x \to \infty} it_{s} I_{s}^{(3)}$ g = 0 the collinear component of the spin current vanishes.

By solving the linear equations generated by Eqs. (8,9), we obtain the spin accumulation s in the normal metal node,

$$s = \hat{C} \qquad [8 \, {}_{c}^{(p)} + W \, {}_{b}] \tag{16}$$

where the elements of the symmetric matrix \hat{C} are given in Appendix A and W $_b = (0;0;2\text{ph}I_0=e)$ is a bias-vector. Eq. (16) contains contribution due to bias current and spin pumping e ect. The spin accumulation in the ferrom agnet Eq. (14) should be substituted in Eq. (16) to give the spin accumulation in the normal metal, from which the spin transfer torque can be determined according to Eq. (6). For an ultrathin lm, the spin transfer torque, including pumping e ect and spin accumulation in the ferrom agnet, reads,

$$L = \frac{_{3}g_{3}}{8} ^{\hat{}} [g_{s}^{\hat{}}] + W_{b}];$$
 (17)

with the elements of listed in Appendix.

B. Dynam ics of the free layer

A first the bias current is switched on, a spin accumulation builds up in the normal metal. At the beginning, the spin-transfer torque exerted on the magnetization of the firee layer (F3) causes a precession out of the plane, hence generating a demagnetizing eld H $_{\rm A}$ that is oriented perpendicular to the lm plane. Subsequently the magnetization precesses around H $_{\rm A}$ and as long as the current I $_{\rm O}$ continues, the rotation persists. In order to determ ine the dynamics of the magnetization, we apply the spin torque term L [Eq. (17)] to the Landau-Lifshitz-G ilbert (LLG) equation (1). C rystalline anisotropies in F3 m ay be disregarded for soft ferrom agnets such as permalloy. The elective eld in the LLG equation then reduces to

$$H_A = {}_{0}M_{s}(N_{x}m_{x};N_{y}m_{y};N_{z}m_{z});$$

$$(18)$$

where N_x , N_y and N_z are the dem agnetizing factors determ ined by the shape of the $lm.^{27}$ The anisotropy eld keeps the magnetization in the plane when the torque is zero. The spin torque generated by the current bias forces the magnetization out of plane, hence triggering the nearly in-plane rotation of the magnetization. Substituting the spin-torque term Eq. (17) into Eq. (1), we obtain for the following LLG equation,

$$\frac{1}{dt} \frac{dm}{dt} = m H_A + \frac{1}{dt} (_0 + _0^!)_m \frac{dm}{dt} + H_{st} (I_0)$$
 (19)

Here the last vector

$$H_{st}(I_0) = \frac{h}{2e} st \frac{I_0}{M_s V} (m_x m_z; m_y m_z; 1 m_z^2) :$$
 (20)

is the e ective eld induced by the spin-transfer torque that depends on the position of the magnetization and the device parameter

$$_{st} = \frac{p_{3}g_{3}G_{1}}{G_{t}G_{3} + 2(p^{2} + 1 +)gG_{1}(1 + m_{z}^{2})};$$
(21)

where G_i 's are introduced in Appendix A.A coording to Eq. (21), we can accurately engineer the device perform ance by tuning the conductances and polarizations. Com pared with the original LLG equation, a new dimensionless parameter entering the calculation

$$! ^{0} = \frac{h (R eg^{"#})^{2}}{2 V M_{S}}$$
 (22)

re ects the tensor character of the pum ping-induced additional G ilbert damping. Choosing contact F 3 N to be metallic and the others to be tunneling barriers, the condition g_3 g_{sf} can be realized. In that $\lim_{t\to\infty} \frac{1}{t} e^{t}$ reduces to

$$^{0} = \frac{h}{4 \text{ VM}_{s}} \text{Reg}_{3}^{"#} ; \tag{23}$$

which agrees with the enhanced G ilbert damping derived in Ref. 22. In the following, we take = 0 + 0 to be the enhanced G ilbert damping constant.

1. Vanishing in-plane anisotropy

Here we rewrite the free layer magnetization in two polar angles (in-plane) and (out-of plane) such that $m = (\cos \cos ; \cos \sin ; \sin)$ and assuming a small z-component, i.e., $m_z = \sin$ and \cos 1. When the free layer is a round at disk with demagnetizing factors $N_x = N_y$ 0 and N_z 1, the Eqs. (49) reduce to:

$$\frac{d}{dt} = \frac{d}{dt} \quad _{0}M_{s}N_{z}$$

$$\frac{d}{dt} = \frac{d}{dt} + F(I_{0}); \qquad (24)$$

introducing $F(I_0) = h_{st}I_0 = (2eM_sV)$. Eq. (24) separates the motion for the in and out-of-plane angles. We consider the dynamics of a current that is abruptly switched on to a constant value I_0 at t=0, assuming that (t=0)=0, i.e., a magnetization that initially lies in the plane. The motion of for t>0 is then given by

$$(t) = \frac{!}{_{0}M_{s}N_{z}} 1 e^{t}$$

$$\frac{d}{dt} = \frac{1}{1 + _{2}}! e^{t} :$$
(25)

where we introduced the response time

In-plane Rotation

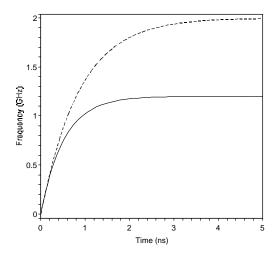


FIG. 2: The in-plane rotation (in the unit of giga hertz) versus time (in nano seconds). The solid line: including spin pumping e ect. The dash line: without spin spumping e ect.

and the saturation in-plane rotation frequency

$$! = \frac{F(I_0)}{I_0} = \frac{h}{2e} st \frac{I_0}{M_0 V}$$
 (27)

Sim ilarly, the in-plane rotation is governed by

$$\frac{d}{dt} = ! t + \frac{!}{0^{M} s^{N} z} 1 e^{t}$$

$$\frac{d}{dt} = ! + \frac{!}{1 + 2} e^{t} : \qquad (28)$$

Taking the parameters from Ref. 12, viz. a volume of normal metal $V_n=400^2-30~\text{nm}^3$, spin ip time in the normal metal of $_{\text{sf}}=62~\text{ps}$, density of states $_{\text{DOS}}=2.4-10^2~\text{eV}^1~\text{m}^3$, we not $e^2g_{\text{sf}}=h=0.3$

Let us take the thickness of the free layer d = 5 nm . The saturation magnetization of permalloy is M $_{\rm S}$ = 8 10^5 A m 1 . The relative mixing conductance is chosen $_3$ ' $_{\rm r}$ ' 1 and the bulk value of the G ilbert damping constant for Py is typically $_0$ = 0:006. A metallic interface conductance (for F 3 N) is typically 1:3f m 2 , whereas the source/drain contacts are tunneling barriers with resistance h= $e^2g=20$ k . The calculated enhancement of the G ilbert damping constant is then 0 = 0:004 and the response time = 0.52 ns. The motion of the magnetization of the free layer is depicted by Fig. 2 and Fig. 3 for a bias current density of J = 10^7 A cm 2 with the cross section at the electronic transport direction 400 2 30 nm².

The spin pumping e ect through the enhanced G ilbert damping constant reduces the saturation frequency from 2.0 to 1.2 GHz, but also the response time to reach the saturation value from 0.87 to 0.52 ns. Notice that the frequency is directly proportional to I_0 and thus in the absence of any in-plane anisotropy the frequency can be tuned continuously to zero by decreasing the bias current. The out-of-plane motion is very slow compared to the in-plane one: it decreases from 12 MHz to around 0 when the in-plane rotation approaches the saturation frequency. As shown in Fig. 4, within a long period the small angle approximation still holds. A larger ratio of g_3 =g also gives higher frequencies. Decreasing the diameter, and thus also the volume, of the free layer gives a smaller demagnetizing factor N_z , which causes larger a response time according to Eq. (26) and increases the saturation value of the in-plane rotation frequency!

2. In-plane an isotropy

In reality, there are always residual anisotropies or pinning centers. Shape anisotropies can be introduced intentionally by fabrication of elliptic F3 discs. We consider the situation in which the free layer is slightly pinned in the plane by an anisotropy eld that corresponds to an elliptic (pancake) shape of the ferrom agnet. At equilibrium, the

Out-of-plane Motion

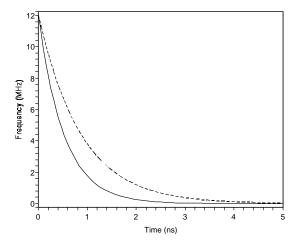


FIG. 3: The out-of-plane motion (in the unit of mega hertz) versus time (in nano seconds). The solid line: including spin pumping e ect. The dash line: without spin pumping e ect.

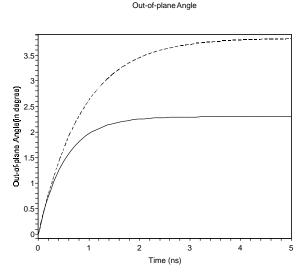


FIG. 4: The out-plane angle (in degree) versus time (in nano seconds). The solid line: including spin pumping e ect. The dash line: without spin spumping e ect.

F3 m agnetization is then aligned along the easy, let us say, x axis. The in-plane rotation can be sustained only when the spin transfer torque overcomes the elective eld generated by the shape anisotropy, hence a critical current I_c for the steady precession is expected. For an ellipse with long axis of 200 nm, thickness 5 nm and aspect ratio 0:9, the two demagnetizing factors are calculated to be N $_{\rm Y}$ = 0:0224 and N $_{\rm X}$ = 0:0191. With a Gilbert damping constant = 0:01, the numerical simulation gives I_c = 4:585 m A corresponding to a current density J_c = 3:8 10^7 A cm 2 (the cross section is 400 30 nm 2).

These critical current densities are of the same order of magnitude as those used to excite the magnetization in spin-valve pillars. So even a relatively small anisotropy can cause a signicant critical current. In order to operate the magnetic fan at small current densities, the magnetic island should be fabricated as round as possible. The magnetization responds to a current step function below the critical value by damped in-plane and out-of-plane oscillations and comes to rest at a new in-plane equilibrium angle $_{\rm e}$ with zero out-plane component (cf. Figs. 5 and 6). At the steady state, the spin-transfer torque is balanced by the torque generated by the in-plane anisotropy, i.e. the angle $_{\rm e}$ is determined by $\sin{(2_{\rm e})} = 2F{(I_0)} = (_{\rm 0}M_{\rm s}(N_{\rm y} N_{\rm x}))$. With given bias current, smaller $N_{\rm y} N_{\rm x}$ correspond to larger in-plane angles j $_{\rm e}$ j. A coording to the theory of differential equations, $N_{\rm x} = 1$ 0 the frequency for the damped magnetization oscillation can be found by diagonalizing the LLG equation at the \equilibrium point" given

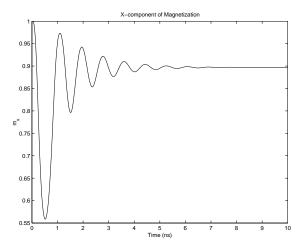


FIG. 5: Below critical current, the x-component of magnetization versus time (in nano seconds). The bias current is 4:5 mA.

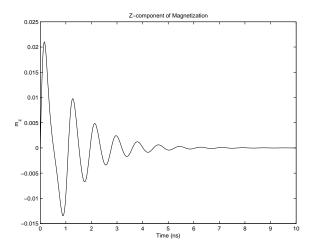


FIG. 6: Below critical current, the z-component of magnetization versus time (in nano seconds). The bias current is 4:5 mA.

by e, this leads to

$$!^{<} = \frac{p_{0}^{M} s^{q}}{2} (2N_{z} N_{x} N_{y})^{p} \overline{D(I_{0})} + D(I_{0});$$
 (29)

w here

$$D (I_0) = (N_y N_x)^2 \frac{4F (I_0)^2}{{}_0^2 M_S^2} :$$
 (30)

Equation (29) teaches us that below the critical current, decreasing the current increases the rotation frequency. Changing the damping constant does not change! $^{<}$ for a given current but only changes the response time to reach the new equilibrium.

As shown by Fig. 7 to Fig. 9 the magnetization above the critical current saturates into a steady precessional state accompanied by an oscillation of the z-component (nutation). In this situation, $_{\rm e}$ is no longer a constant of motion. Instead the new steady state is given by m $_{\rm x}$ = m $_{\rm y}$ = 0 and m $_{\rm z}$ = F (I $_{\rm 0}$)=($_{\rm 0}$ M $_{\rm s}$ N $_{\rm z}$). Diagonalizing the LLG around this point we derive the in-plane rotation frequency

$$!^{>} = \frac{F (I_0)}{N_z} \frac{p}{N_z N_x) N_z N_y} :$$
(31)

In the lim it of vanishing in-plane anisotropy, i.e., $N_x = 0$ and $N_y = 0$, we recover the previous result. As shown by

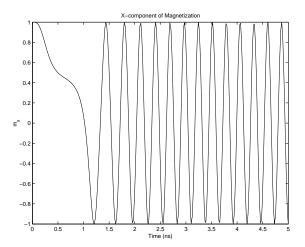


FIG. 7: Above the critical current, the x-component of magnetization versus time (in nano seconds). The bias current is 4.6 m A. The frequency is about 3.6 G H z.

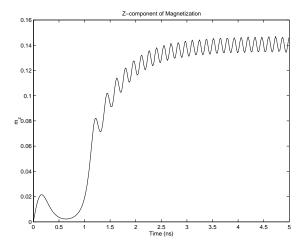


FIG. 8: Above critical current, the z-component of magnetization versus time (in nano seconds). The bias current is 4:6 mA.

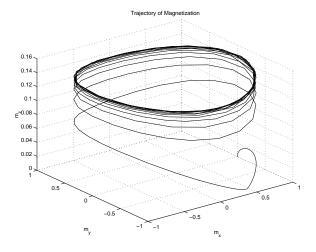


FIG. 9: Above critical current, the trajectory of magnetization within 5 nano seconds. The bias current is 4:6 m A. This picture clearly shows the steady precession of the magnetization.

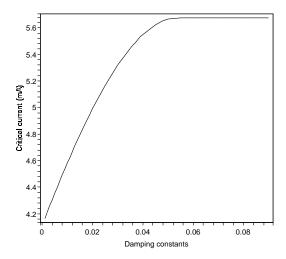


FIG. 10: The critical current I_{c} versus damping constant . This gure shows saturation of I_{c} above a critical .

Fig. 10, the dependence of the critical current on the damping constant is different from the simple proportionality predicted for pillar structures. Specifically we observe saturation of the critical current above a critical damping.

In the anisotropic case the extra power processory for maintaining the motion generates microwaves. We high many

In the anisotropic case the extra power necessary for maintaining the motion generates microwaves, 5,6 which may be attractive for some applications.

IV. APPLICATIONS

Our \m agnetic fan" has the advantage that the m agnetization dynam ics is not hidden within the structure as in the pillars, but is open to either studies of the dynam ics by fast m icroscopy, or to the utilization of the dipolar eld from the soft m agnetic island. We envisage applications as m agnetic actuators for nanom echanical cantilevers and nanoscale m otors, as nanoscale m ixers of biological or biom edical suspensions containing m agnetic nanoparticles, or as m agnetic resonance detectors, again possibly useful for biom edical applications.

A. Actuators

The rotating m agnetization of the \m agnetic fan" generates a periodic dipolar eld which can be applied to actuate a nanom echanical cantilever with a (hard) ferrom agnetic tip. A ssum ing for simplicity that the m agnet F3 and the cantilever are at a su ciently large distance the force on the cantilever m agnet is given by

$$F = V_c r \left(M_c \quad H_d \right); \tag{32}$$

where M $_{\rm c}$ is the saturation m agnetization and V $_{\rm c}$ is the volume of the cantilever m agnet and the eld H $_{\rm d}$ generated by a magnetic dipolar at the position r can be written as

$$H_d = {}_0 \frac{3 (M - r)r - M^2 r}{r^5}$$
: (33)

A ssum e a cantilever on top of the magnetic fan at a distance of 125 nm (along z-direction), 31 with beam plane parallel to the plane of the Py lm F3 and magnetization along the x-axis. The saturation value of cantilever magnetization is taken as $1.27 10^6$ A m 1 . Assuming a lateral size of the cantilever magnet of 150 31 of 150 31 with thickness 50 nm, the force is estimated to be

$$F = 1.1 10^8 cos(! t) N (34)$$

where ! is the rotation frequency of the \mbox{m} agnetic fan". To e ciently generate the mechanical modes of the cantilever, the cantilever magnet should be hard enough.

Fixing other param eters, the force scales like $1=r^4$ with respect to distance r. When the two ferrom agnets are closer to each other the distribution of the magnetizations increases the force over the value estimated above. We see that in the dipole-approximation, the force is already quite signicant and it will be signicantly larger when the full magnetostatic energy is computed.

Generally, the torque on the cantilever may generate both exural and torsional motion on the cantilever. The torsional motion coupled to the magnetization dynamics has been investigated for such a system 32 and the nanomerchanical magnetization reversal based on the torsional modes has been proposed. The coupling of a cantilever to the oscillating dipolar eld will be discussed elsewhere.

B. Mixers

The dipolar eld produced by our device can also be used to function as mechanical mixer for suspensions of magnetic particles. To this end we should scale down the frequency of the rotating magnetization either by decreasing the bias current or re-engineering the parameters of the device, e.g., increasing the thickness of the Py lm. Low saturation magnetization is detrimental in this case, since that would also reduce the usable stray elds. By these ways, one hopefully can access the kilo hertz frequency region, which is important for the hydrodynamic motion in ferro uids.³⁴

C. Detectors

An external eld in uences the frequency of the rotation of the magnetization. Response to the change of the frequencies is the rebuilding of the spin accumulation in the normal metal hence altering the source-drain resistance R_{SD} . Due to the relation

$$_{0}^{\text{F1}}$$
 $_{0}^{\text{F2}} = R_{\text{SD}} I_{0};$ (35)

this deviation is re-ected on the source-drain voltage-current curve. This feature can be implemented as a sensor for biomedical applications in order to detect the presence of magnetic beads, which are used as labels in biosensors. Furthermore, the ability to change the frequency of the \magnetic fan" should allow to measure locally the frequency dependence of the magnetic susceptibility, which o ers an alternative pathway to using magnetic nanoparticles for biosensing applications. 36,37

V. CONCLUSION

We studied the magnetization dynamics of a magnetic transistor, i.e., a lateral spin valve structure with perpendicular-to-plane magnetizations and an in-plane free layer attached to the normal metal that is excited by an external current bias. By circuit theory and the Landau-Lifshitz-Gilbert equation, analytic results were obtained for the spin-transfer torque and the dynamics of the magnetization in the limit of small out-of-plane angle. Spin ip and spin-pumping elects were also investigated analytically and an anisotropic enhanced Gilbert damping was derived for the free layer magnetization. Without an externally applied magnetic eld, a continuous rotation of the magnetization of the free layer at GHz frequencies can be achieved. In the lateral geometry, the free layer is no longer buried or penetrated by a dissipating charge current, thus becomes accessible for more applications. Our methods handle the microscopic details on crucial issues like spin-torque transfere ciency, spin-ip scattering and the response time, hence of ering accurate design and control. The rotation can be observed, e.g., by magneto-optic methods. This new device has potential applications as high frequency generator, actuator of nanomechanical systems, biosensors, and other high-speed magnetoelectronic devices.

A cknow ledgm ents

We thank Yu. V. Nazarov, J. Slonczewski and A. Kovalev for fruitful discussions. X.W ang acknowledges H. Saarikoski's help with the preparation of the manuscript. This work is supported by NanoNed, the FOM, U.S. Department of Energy, Basic Energy Sciences, under Contract No.W -31-109-ENG-38 and the EU Commission FP 6 NMP-3 project 505587-1 \SFINX". GEW B would like to acknowledge the support through the Materials Theory Institute and the hospitality he enjoyed at Argonne.

APPENDIX A: SPIN ACCUMULATION IN NORMAL METAL NODE

Here we sum marize a number of complex angle dependent coe cients. The elements of the sym metric matrix \hat{C} in Eq.(16) read

$$C_{11} = \frac{G_{t} (G_{1} - G_{1} m_{x}^{2}) - 2g (p^{2} - 1 +) (G_{t} - G_{1} m_{y}^{2})}{O}$$
(A 1)

$$C_{12} = C_{21} = \frac{G_2G_4m_xm_y}{Q}$$
; and $C_{13} = C_{31} = \frac{G_tG_4m_xm_z}{Q}$ (A2)

$$C_{22} = \frac{G_2 (G_t - G_t m_x^2) - G_t G_4 m_z^2}{Q}$$
 (A 3)

$$C_{23} = C_{32} = \frac{G_t G_4 m_y m_z}{Q}$$
; and $C_{33} = \frac{G_t (G_1 + G_4 m_z^2)}{Q}$ (A 4)

introducing

$$G_1 = (1 p_3^2)(1 g_3)g_3 + 2 g + 2g_{sf}$$
 (A.5)

$$G_2 = {}_{3}g_{3} + 2(1 \quad p^{2})g + 2g_{sf}$$
 (A 6)

$$G_3 = (1 \quad p_3^2) (1 \quad _3)g_3 + 2(1 \quad p^2)g + 2g_{sf}$$
 (A7)

$$G_4 = {}_{3}g_{3}$$
 (1 \mathring{R}) (1 ${}_{3}$) g_{3} (A 8)

$$G_t = {}_{3}g_3 + 2 g + 2g_{sf}$$
 (A 9)

$$Q = G_t [G_t G_3 + 2 (p^2 1 +) gG_t (1 m_z^2)]$$
(A 10)

$$_{3} = \frac{_{3}}{_{3} + \sim \tanh (d = \mathbb{F}_{d})};$$
 (A 11)

in the lim it of negligible spin ip in F, i.e., d l_{sd}^{F} , then l_{sd}^{F} . The elements of the matrix in Eq. (17) are given by

$$_{11} = \frac{G_{t}G_{3} (1 - m_{x}^{2}) + 2G_{4} (p^{2} - 1 +)gm_{y}^{2}}{O}$$
 (A 12)

$$_{12} = _{21} = \frac{G_1 G_2 m_x m_y}{O};$$
 and $_{13} = \frac{G_2 G_1 m_x m_z}{O}$ (A.13)

$$_{22} = \frac{G_{t}G_{3} (1 - m_{y}^{2}) + 2G_{4} (p^{2} - 1 +)gm_{x}^{2}}{O}$$
 (A 14)

$$_{23} = \frac{G_t G_1 m_y m_z}{Q}$$
; and $_{31} = \frac{G_t G_3 m_x m_z}{Q}$ (A 15)

$$_{32} = \frac{G_t G_3 m_y m_z}{O}$$
; and $_{33} = \frac{G_t G_1 (1 m_z^2)}{O}$ (A 16)

(A 17)

¹ J.C.Slonczewski, J.M agn.M agn.M ater. 159, L1 (1996).

² L.Berger, Phys. Rev. B 54, 9359 (1996).

J.A.Katine, F.J.Albert, R.A.Buhrman, E.B.Myers, and D.C.Ralph, Phys.Rev.Lett.84, 3149 (2000).

E.B.M yers, F.J.A lbert, J.C. Sankey, E.Bonet, R.A.Buhrm an, and D.C.Ralph, Phys.Rev.Lett.89, 196801 (2002).
 S.I.K iselev, J.C. Sankey, I.N.K rivorotov, N.C.Em ley, R.J. Schoelkopf, R.A.Buhrm an, and D.C.Ralph, Nature (London) 425, 380 (2003).

 $^{^6}$ W .H.R ippard, M.R.Pufall, S.Kaka, S.E.Russek, and T.J.Silva, Phys.Rev.Lett.92,027201 (2004).

⁷ A.Kent, B.Ozyilm az, and E.del Barco, App. Phys. Lett. 84, 3897 (2004).

⁸ K.J.Lee, O.Redon, and B.Dieny, App. Phys. Lett. 86, 022505 (2005).

⁹ H.Xi, K.Z.Gao, and Y.Shi, J.Appl.Phys. 97, 044306 (2005).

- ¹⁰ F.J. Jedem a, A.T. Filip, and B.J. van W ees, Nature 410, 345 (2001).
- ¹¹ F.J.Jedem a, H.B.Heersche, A.T.Filip, J.J.A.Baselm ans, and B.J.van Wees, Nature 416, 713 (2002).
- ¹² M . Za alon and B . J. van W ees, Phys. Rev. Lett. 91, 186601 (2003).
- ¹³ T. K im ura, J. H am rle, Y. Otani, K. Tsukagoshi, and A. Aoyagi, App. Phys. Lett. 85, 3501 (2004).
- 14 S.O. Valenzuela and M. Tinkham, App. Phys. Lett. 85, 5914 (2004).
- ¹⁵ Y.Ji, A.Ho mann, J.S.Jiang, and S.D.Bader, App. Phys. Lett. 85, 6218 (2004).
- ¹⁶ G.E.W. Bauer, A.Brataas, Y.Tserkovnyak, and B.J. van Wees, App. Phys. Lett. 82, 3928 (2003).
- E. Saitoh, H. Miyajima, T. Yamaoka, and G. Tatara, Nature (London) 432, 203 (2004).
- ¹⁸ J.G rollier, M.V.Costache, C.H. van der Wal, and B.J. van Wees, cond-mat/0502197 (2005).
- $^{19}\,$ T . K im ura, Y . O tani, and J. H am rle, cond-m at/0508559 (2005).
- $^{20}\,$ A . B rataas, Y . V . N azarov, and G . E . W . B auer, P hys. R ev . Lett. 84, 2481 (2000).
- ²¹ P.F.Carcia, J.Appl.Phys.63, 5066 (1988).
- Y. Tserkovnyak, A. Brataas, and G. E. W. Bauer, Phys. Rev. Lett. 88, 117601 (2002).
- ²³ Y. Tserkovnyak, A. Brataas, G. E. W. Bauer, and B. I. Halperin, cond-mat/0409242 (2004).
- ²⁴ I.N.Krivorotov, N.C.Em ley, J.C.Sankey, S.I.Kiselev, D.C.Ralph, and R.A.Buhrman, Science 307, 228 (2005).
- ²⁵ J. X iao, A. Zangwill, and M. D. Stiles, Phys. Rev. B 72, 014446 (2005).
- ²⁶ A.Brataas, Y.V.Nazarov, and G.E.W.Bauer, Eur.Phys.J.B 22, 99 (2001).
- ²⁷ J.A.O sborn, Phys. Rev. 67, 351 (1945).
- 28 X.W ang and G.E.W .Bauer, unpublished (2004).
- ²⁹ A.Kovalev, G.E.W. Bauer, and A.Brataas, cond-mat/0504705 (2005).
- 30 L.Perko, Di erential Equations and Dynam ical Systems (Springer, Berlin, 1996), 2nd ed.
- ³¹ D.Rugar, R.Budakian, H.J.M am in, and B.W. Chui, Nature 430, 329 (2004).
- ³² A.A.Kovalev, G.E.W. Bauer, and A.Brataas, App. Phys. Lett. 83, 1584 (2003).
- 33 A . A . K ovalev, G . E . W . B auer, and A . B rataas, P hys. R ev. Lett. 94, 167201 (2005).
- 34 M .I.Shliom is and V .I.Stepanov, Adv.Chem .Phys.87,1 (1994).
- D.R.Baselt, G.U.Lee, M.Natesan, S.W.Metzger, P.E.Sheehan, and R.J.Colton, Biosens. Bioelectron. 13, 731 (1998).
- $^{36}\,$ J.Connoly and T.G.StPierre, J.Magn.Magn.Mater.225, 156 (2001).
- ³⁷ S.H.Chung, A.Ho mann, S.D.Bader, C.Liu, B.Kay, L.Makowski, and L.Chen, App. Phys. Lett. 85, 2971 (2004).